

Amendment Under 37 C.F.R. § 1.111
U.S. Application No. 10,644,964

IN THE SPECIFICATION:

Please amend Table 3, by replacing “TaB (Ta:B=4:1) with --Ru--.”

A new page 29 incorporating the amendment is attached herewith.

Table 3

Example 3 (Heating Condition 200 °C, 60 min)

In case where the stress correction film is formed on the multilayer reflection film

	Material	Film Thickness nm	Surface Roughness mmRms	Before Heating			After Heating		
				Stress Mpa*)	Stress x Film Thickness Pa · cm	Flatness nm	Stress Mpa*)	Stress x Film Thickness Pa · cm	Flatness nm
Stress Correction Film	Ru	10	0.15	+20 (+580)	+580	50	+138 (+4000)	+4000	
Multilayer Reflection Film	Mo/Si 40 periods	290	0.15	-450	-13050	1200	-200	-5800	
Stress Correction Film + Multilayer Reflection Film				-430	-12470	1150	-62	+1800	80

*) The value outside of () shows the film stress corresponding to the film thickness of the multilayer reflection film,
the value inside of () shows the film stress per unit film thickness